China

CMC

COA

Sihcl3

Cylinder/Tank

Trichlorosilane

99.99% Electron Grade

By Sea

Sihcl3

Tanker

China

Sihcl3

7783-82-6

Industrial Pure Air

Y-Cylinder CMC

2812190091

500ton/Month 10025-78-2

Trichlorosilane Good Price High Purity Semiconductor Industry Application Usage Sihcl3

Basic Information

- Place of Origin:
- Brand Name:
- Certification:
- Model Number:
- Minimum Order Quantity: 1kg
- Price: US \$500/kg
- Packaging Details:
- Delivery Time: 30 days
- Payment Terms: L/C, T/T
- Supply Ability: 200 Tons/Year

Product Specification

- Product Name:
- Purity:
- Grade:
- Transport:
- Model No.:
- Transport Package:
- Specification:
- Trademark:
- Origin:
- HS Code:
- Supply Ability:
- CAS No.:
- Formula:EINECS:
- EINEOU.
- Constituent:



SiHCI3

More Images









Product Description

Product Description

Trichlorosilane (SiHCl3) is a chemical compound composed of one silicon atom bonded to three chlorine atoms and one hydrogen atom. It is a colorless, volatile liquid that has a pungent odor. Here are some key points about trichlorosilane:

Chemical Composition: Trichlorosilane consists of one silicon (Si) atom bonded to three chlorine (Cl) atoms and one hydrogen (H) atom. Its chemical formula is SiHCl3.

Properties: Trichlorosilane is a volatile liquid with a boiling point of -30.8 degrees Celsius (-23.4 degrees Fahrenheit) and a melting point of -120.1 degrees Celsius (-184.2 degrees Fahrenheit). It has a characteristic odor similar to that of hydrochloric acid.

Production: Trichlorosilane is primarily produced through the reaction of metallurgical-grade silicon (usually derived from quartz or silicon dioxide) with hydrogen chloride (HCl) gas:

Si + 3HCl → SiHCl3 + H2

This reaction typically occurs at high temperatures in the presence of a catalyst, such as copper, to facilitate the reaction.

Uses: Trichlorosilane has various industrial applications:

Silicon Production: It is a key precursor in the production of polycrystalline silicon, which is widely used in the manufacturing of solar cells, semiconductors, and electronics.

Chemical Synthesis: Trichlorosilane is utilized as a starting material or intermediate in the synthesis of various silicon-based compounds, including silanes, silicones, and high-purity silicon.

Semiconductor Industry: It is used as a source material for the chemical vapor deposition (CVD) process, where trichlorosilane is decomposed to deposit thin layers of silicon on semiconductor wafers.

Optical Fiber Manufacturing: Trichlorosilane is used in the production of high-purity silica glass, which is essential for optical fibers and other optical components.

Safety Considerations: Trichlorosilane is flammable and may react violently with water or moisture, releasing hydrogen chloride gas. It is corrosive to metals and can cause skin and eye irritation. Proper safety precautions, such as using appropriate protective equipment and handling procedures, should be followed when working with trichlorosilane.

It's important to handle trichlorosilane with care and adhere to safety measures to mitigate potential risks associated with its reactivity and corrosiveness.

Basic Info.

ר ר

| Model No: | SiHCI3 | Quality | Electron Grade |
|-------------------|--------------------------------|---------------------|---------------------------------|
| Transport Package | Y-Cylinder, T-Drum, Tt, Tanker | Specification | 20L, 40L, 280L and customizable |
| Trademark | CMC | Origin | Suzhou, China |
| HS Code | 2812190091 | Production Capacity | 500ton/Month |

Specification:

Trichlorosilane is a silicon precursor for epitaxial silicon-containing thin films, especially for the preparation of starting wafers.

| Purity %: | ≥99.85 | |
|----------------------------------|--------------------|--|
| Resistivity: | ≥ 300 ohm-cm | |
| Boron: | ≤ 0.1 ppba silicon | |
| Total Carbon: | ≤ 5 ppma | |
| Iron: | ≤ 5 ppba | |
| Other Chlorosilane : | ≤ 500 ppm | |
| Cylinder State @ 21.1°C : | Liquid | |
| Flammable Limits In Air : | 7-83% | |
| Auto Ignition Temperature (°C): | 182 | |
| Molecular Weight (g/mol): | 135.45 | |
| Specific gravity (air =1): | 4.67 | |
| Critical Temperature (°C): | 242.5 | |

Detailed Photos





Shanghai Kemike Chemical Co., Ltd is staffed by trained personnel, combine many years experience in Gas industry .We supply cylinder gas, electronic gas, etc., and the gas holder, panel, valves and fittings and other equipment, parts and engineering services to our customers in China and worldwide; The products are involved in various industrial fields, such as semiconductor chip, solar cell, LED, TFT-LCD, optical fiber, glass, laser, medicine, etc., Our mission is to partner with our global customers to provide support, solutions and quality products that are innovative, reliable, and safe. Our products mainly include: H2, O2, N2, Ar, CO2, propane, acetylene, helium, laser mixed gas, SiH4, Sih2cl2, SiHCL3, SiCL4, NH3, CF4, NF3, SF6, HCL, N2O, doping mixed gas (TMB, PH3, B2H6) and other electronic gases.



III Shanghai Kemike Chemical Co.,Ltd

williamchen@cmc-chemical.com

@ gascylindertank.com